



Docket No.: 241675US0

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313



ATTORNEYS AT LAW

NORMAN F. OBLON
(703) 413-3000
NOBLON@OBLON.COM

JAMES J. KELLY, PH.D.
(703) 413-3000
JKELLY@OBLON.COM

RE: Application Serial No.: 10/642,694

Applicants: Igor ROZHANSKII, et al.

Filing Date: August 19, 2003

For: NOVEL AROMATIC SULFONIC ACID ESTER
DERIVATIVE, POLYARYLENE, POLYARYLENE
HAVING SULFONIC ACID GROUP AND PROCESS
FOR PRODUCING THE SAME, AND POLYMER
SOLID ELECTROLYTE AND PROTON-
CONDUCTIVE MEMBRANE

Group Art Unit: 1711

Examiner: D. TRUONG

SIR:

Attached hereto for filing are the following papers:

REQUEST FOR RECONSIDERATION

Our credit card payment form in the amount of **\$0.00** is attached covering any required fees. In the event any variance exists between the amount enclosed and the Patent Office charges for filing the above-noted documents, including any fees required under 37 C.F.R. 1.136 for any necessary Extension of Time to make the filing of the attached documents timely, please charge or credit the difference to our Deposit Account No. 15-0030. Further, if these papers are not considered timely filed, then a petition is hereby made under 37 C.F.R. 1.136 for the necessary extension of time. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

OBLON, SPIVAK, McCLELLAND,
MAIER & NEUSTADT, P.C.
Norman F. Oblon

Customer Number

22850

(703) 413-3000 (phone)
(703) 413-2220 (fax)


James J. Kelly, Ph.D.

Registration No. 41,504

DOCKET NO: 241675US0



IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF

:

IGOR ROZHANSKII, ET AL.

: EXAMINER: D. TRUONG

SERIAL NO: 10/642,694

:

FILED: AUGUST 19, 2003

: GROUP ART UNIT: 1711

FOR: NOVEL AROMATIC SULFONIC ACID ESTER DERIVATIVE,
POLYARYLENE, POLYARYLENE HAVING SULFONIC ACID GROUP AND
PROCESS FOR PRODUCING THE SAME, AND POLYMER SOLID
ELECTROLYTE AND PROTON-CONDUCTIVE MEMBRANE

REQUEST FOR RECONSIDERATION

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

Responsive to the Office Action dated June 8, 2006, Applicants respectfully request reconsideration of the above-identified application in view of the following remarks:

Remarks begin on page 2 of this paper.